

FIG. 1
(PRIOR ART)

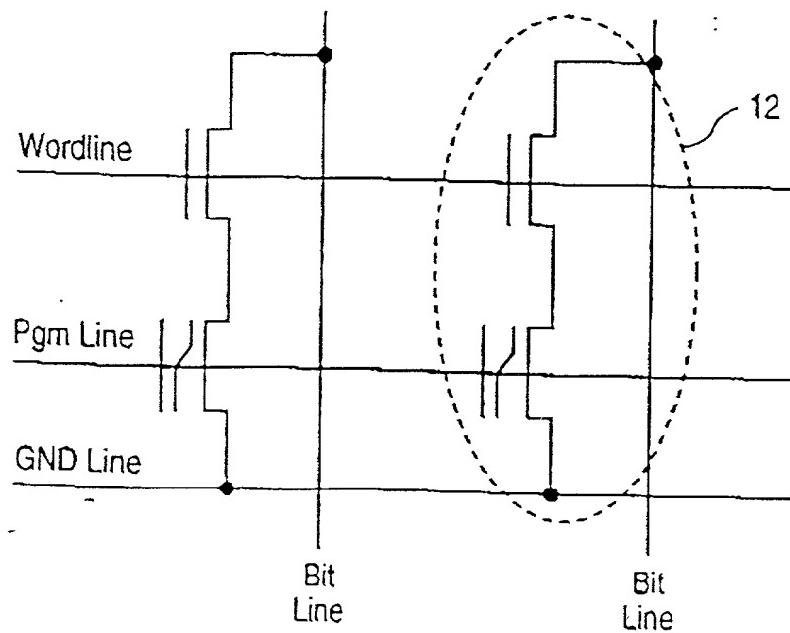


FIG. 2
(PRIOR ART)

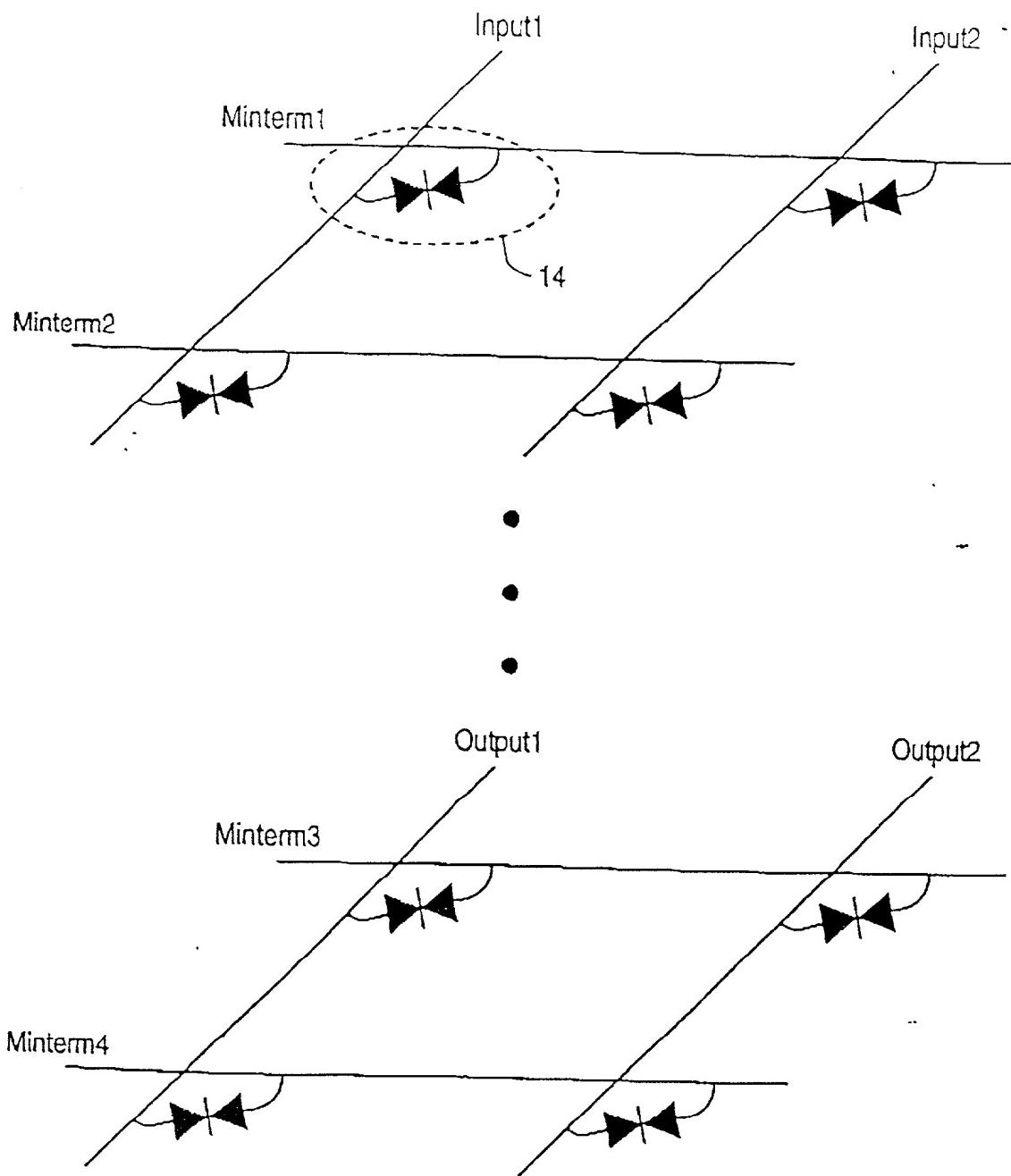


FIG. 3
 (PRIOR ART)

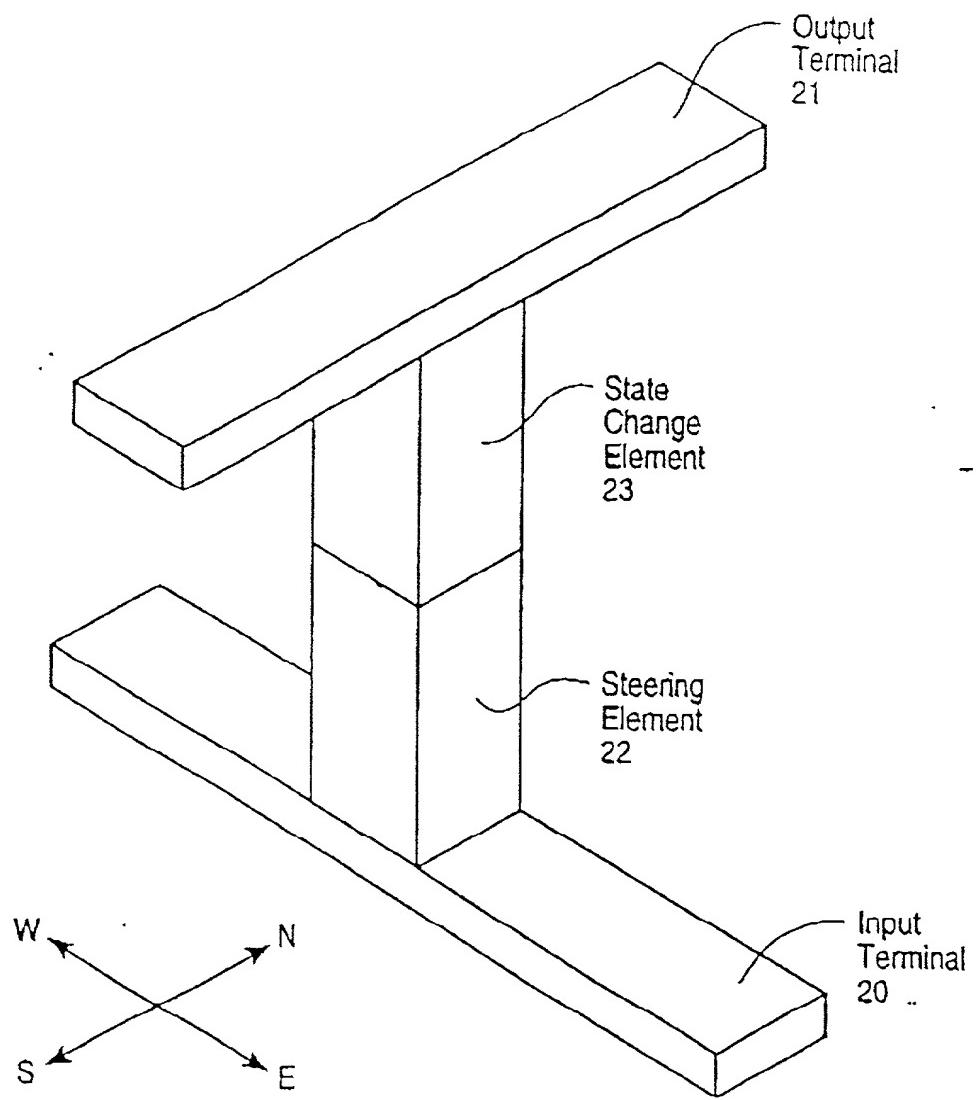


FIG. 4(a)

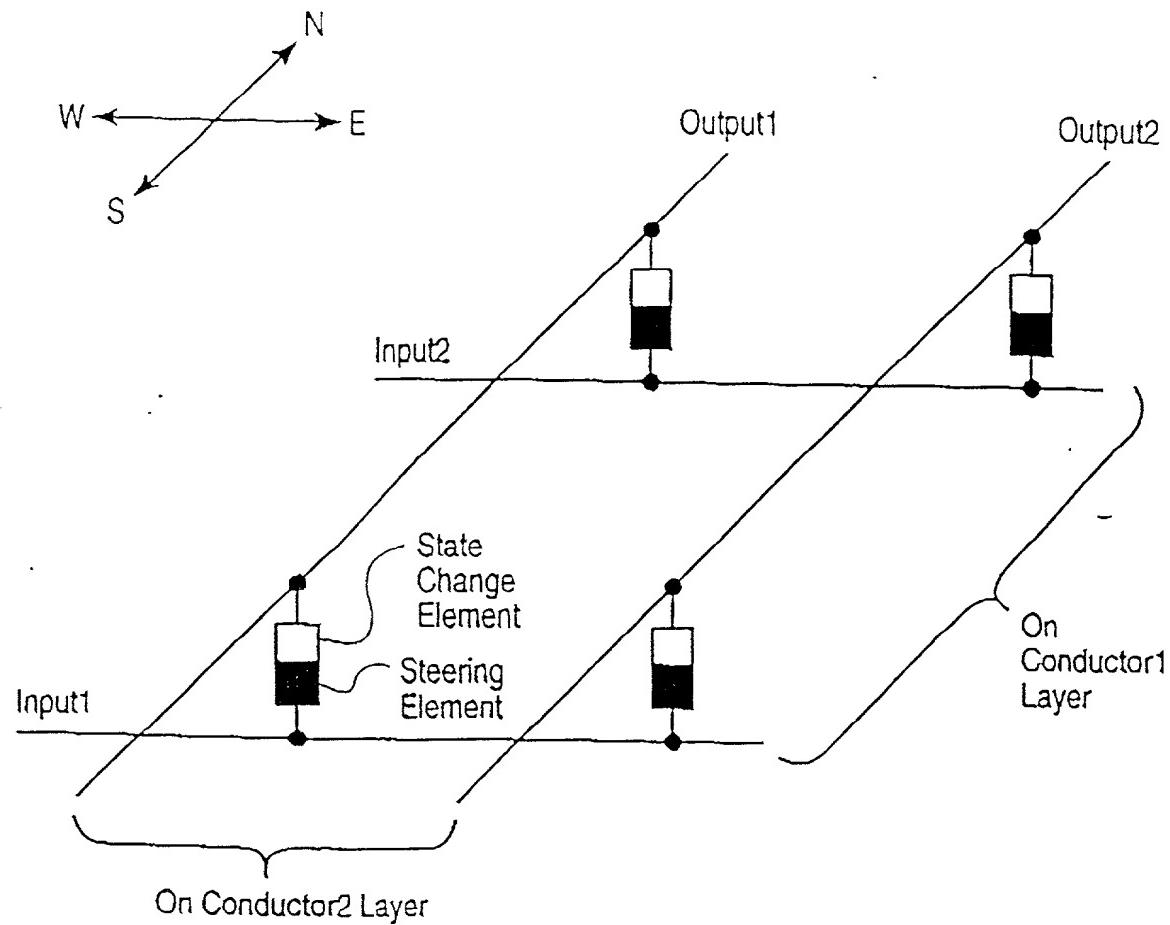


FIG. 4(b)

FIG. 5 shows a cross-section of a conductor system supported by pillars.

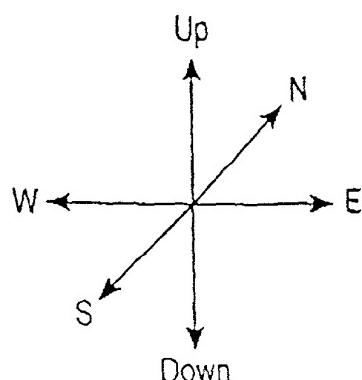
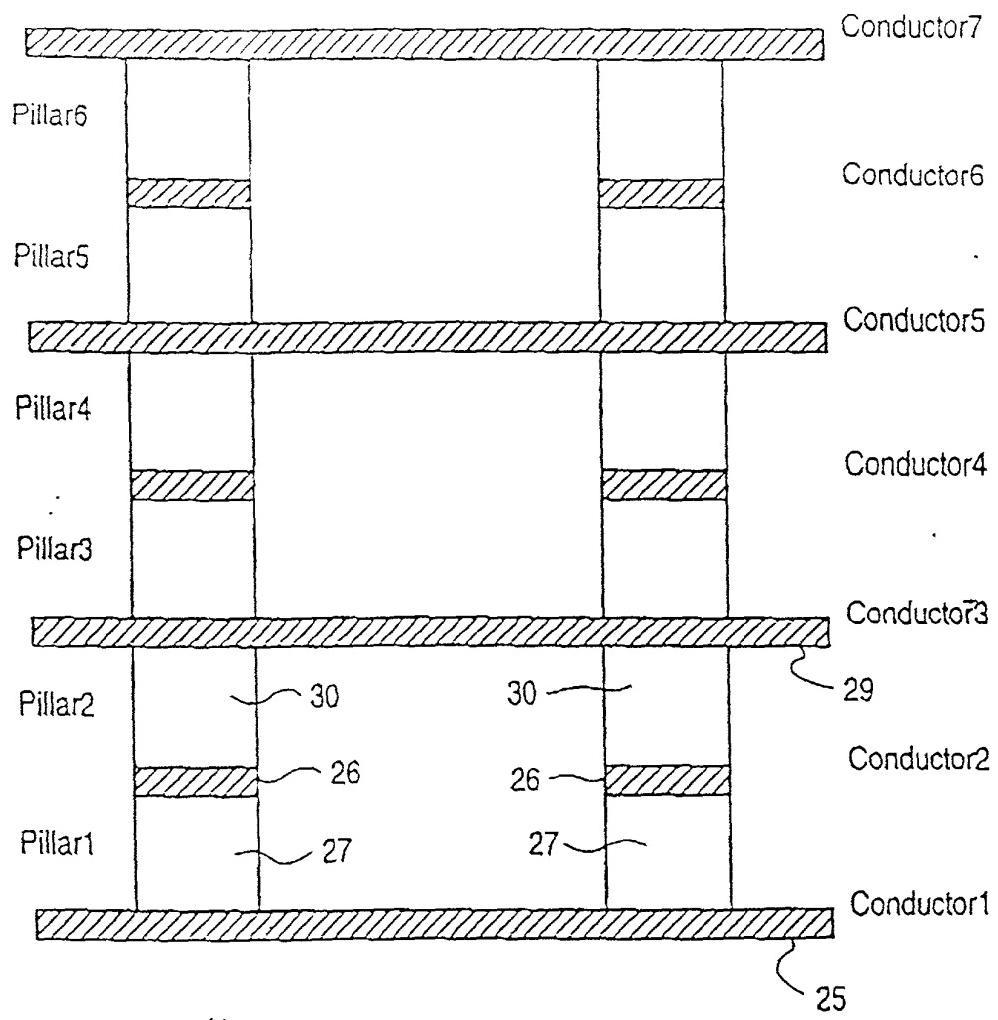


FIG. 5

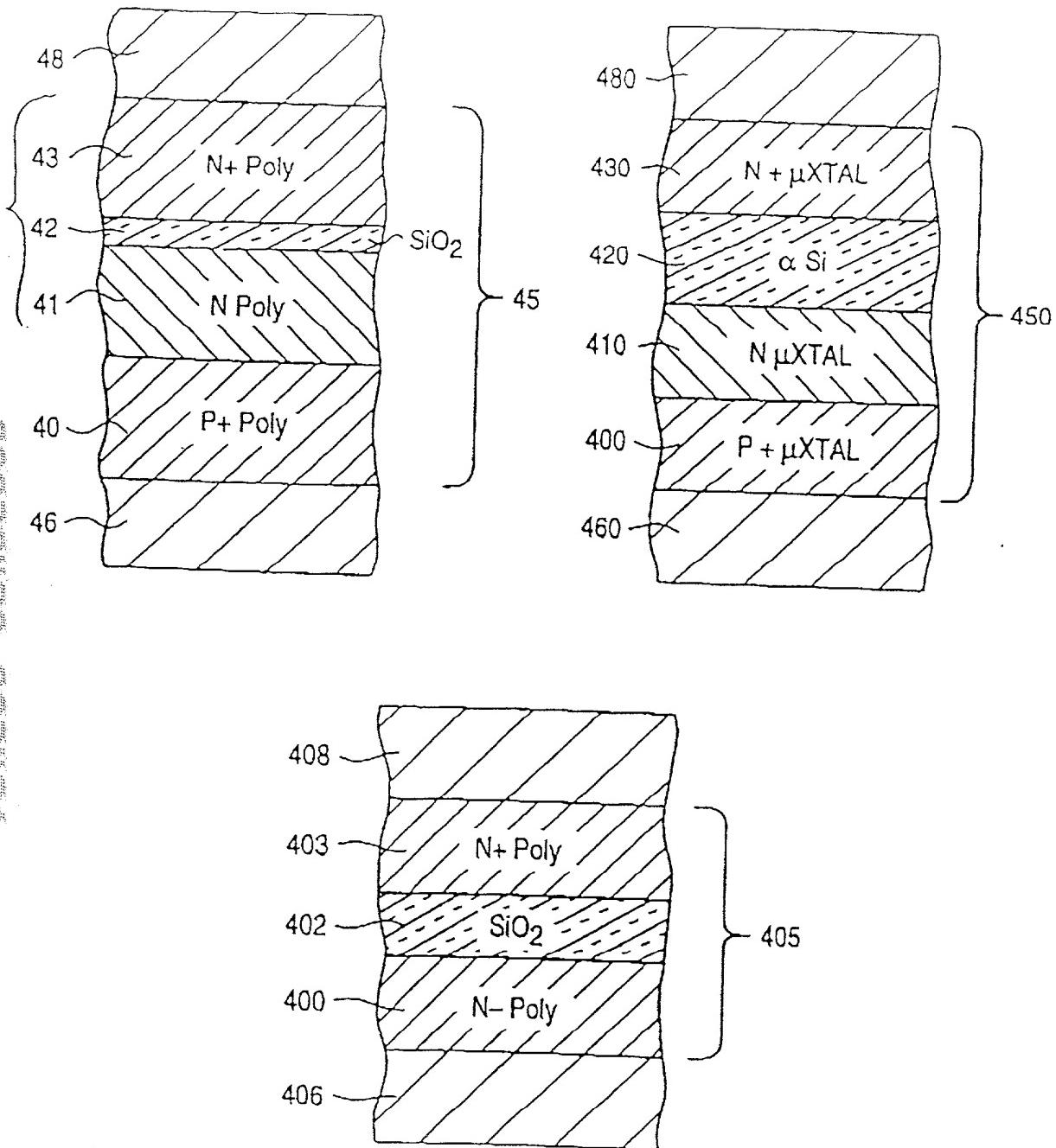


FIG. 6(a)

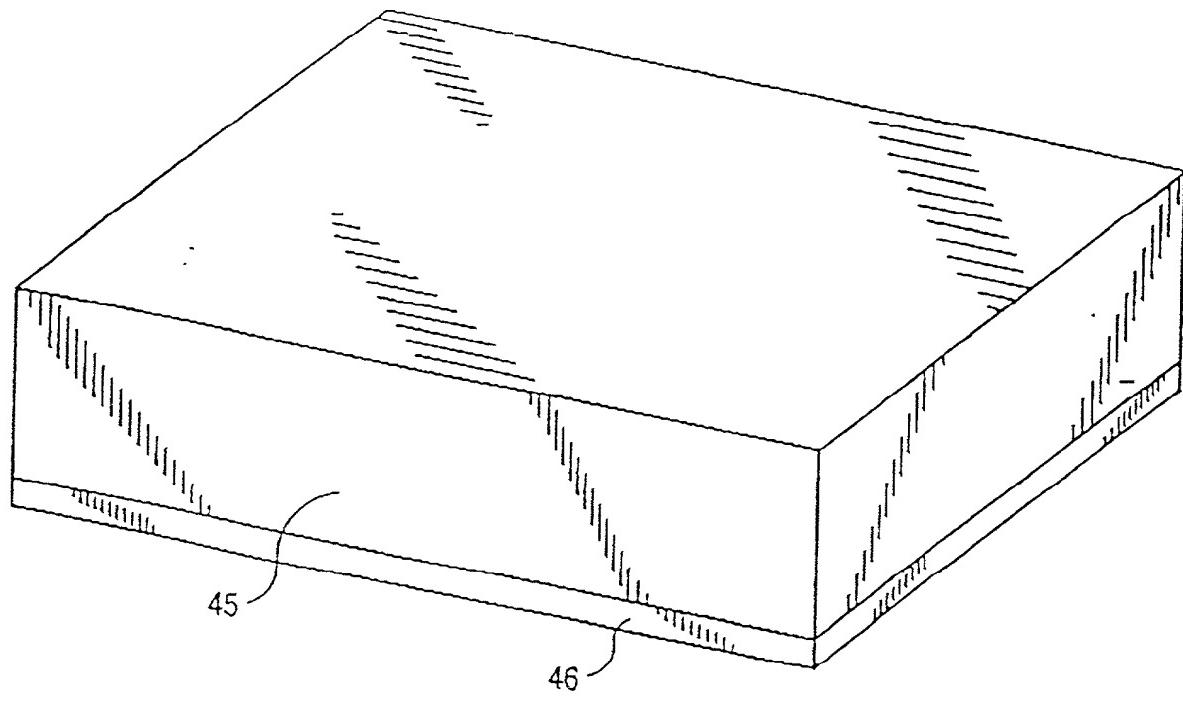


FIG. 6(b)

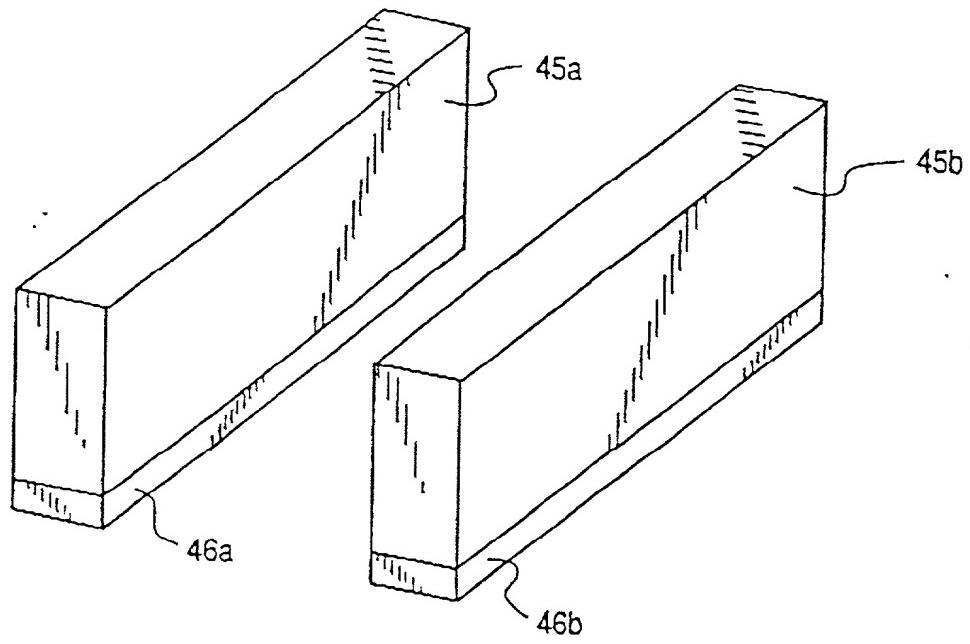


FIG. 6(c)

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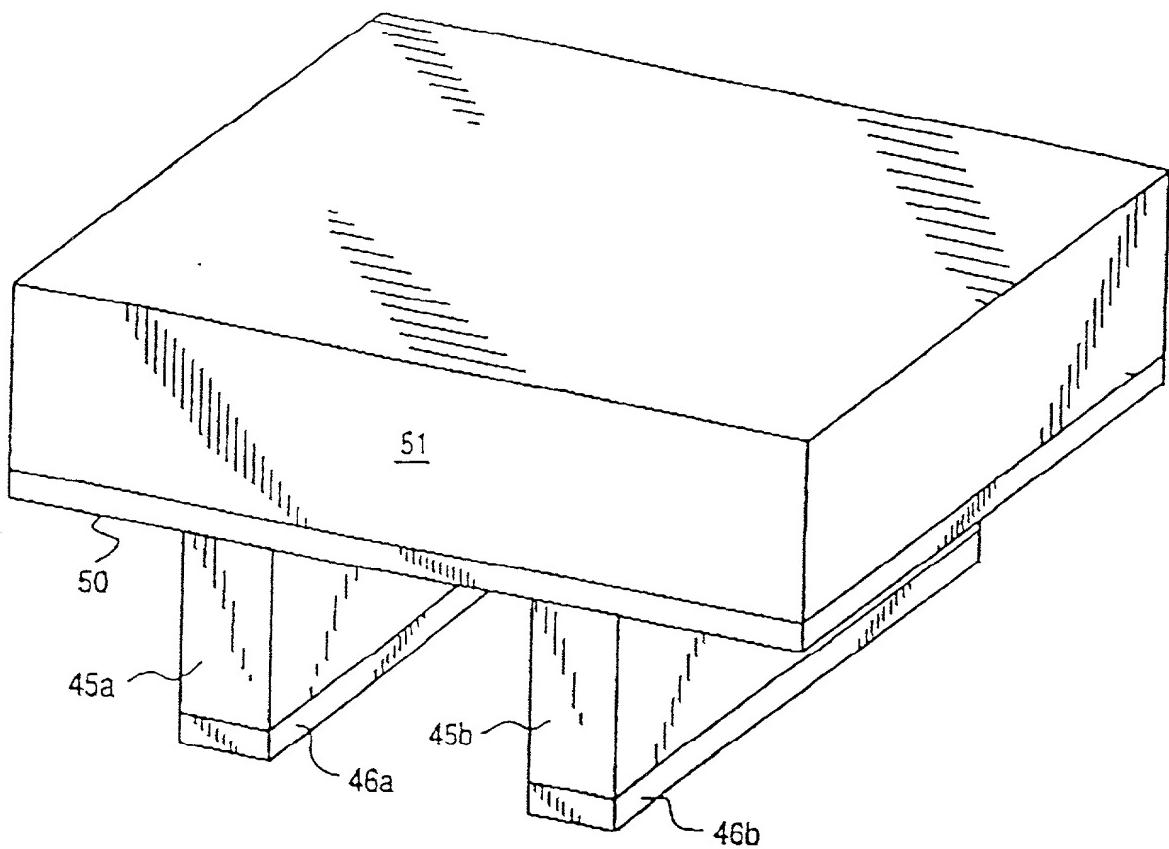


FIG. 6(d)

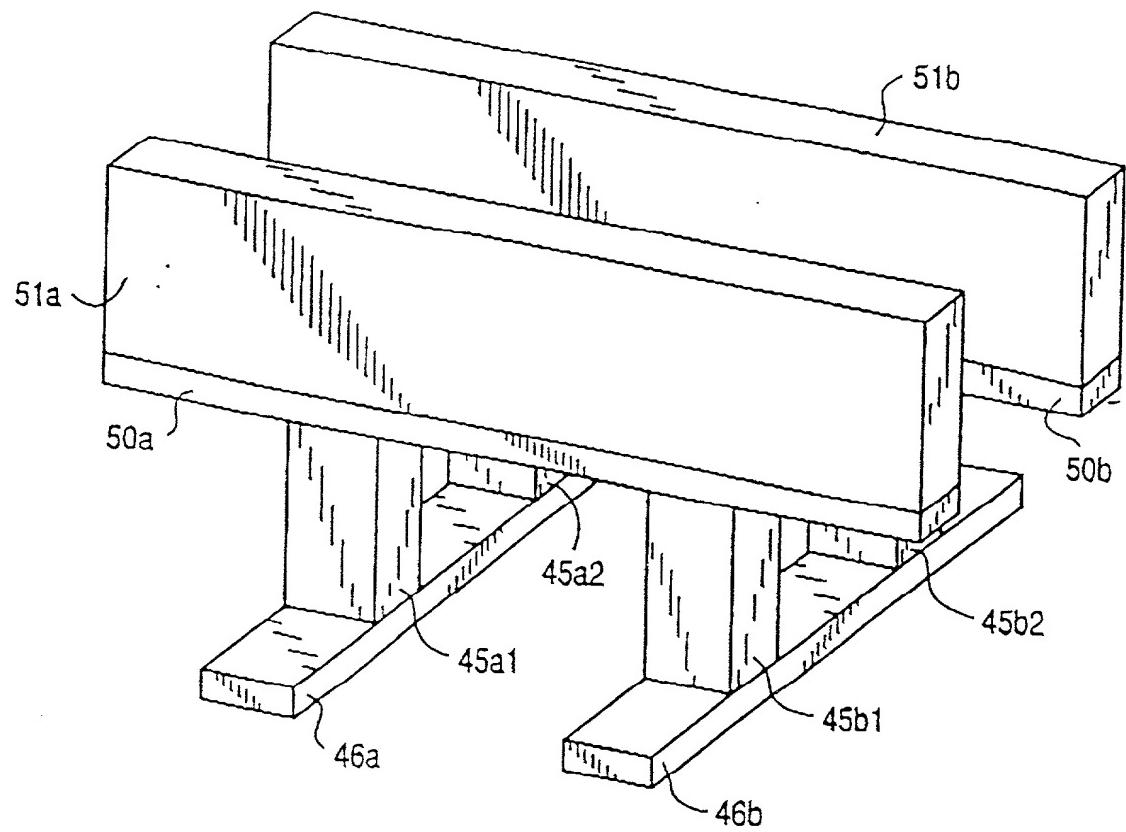


FIG. 6(e)

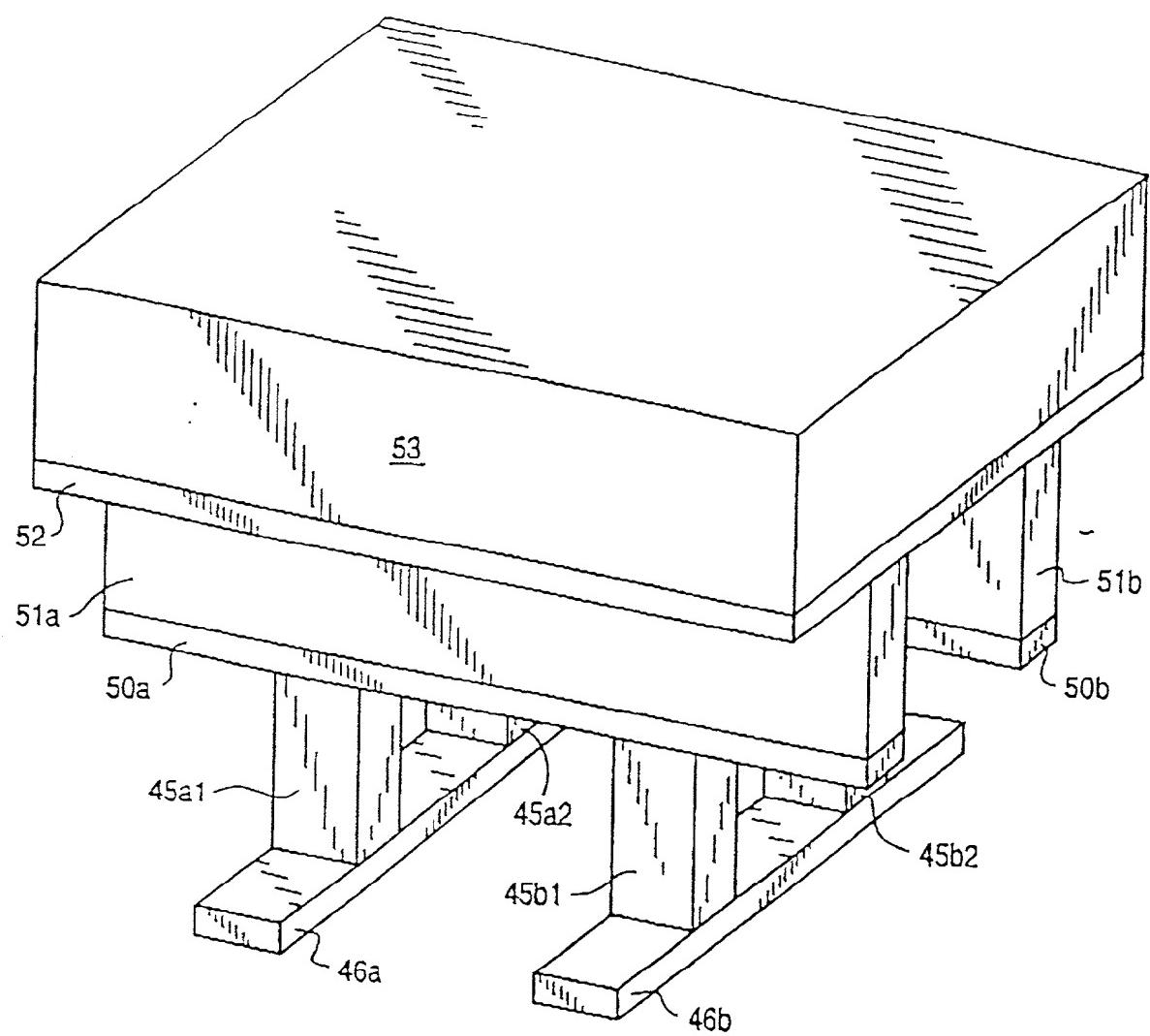


FIG. 6(f)

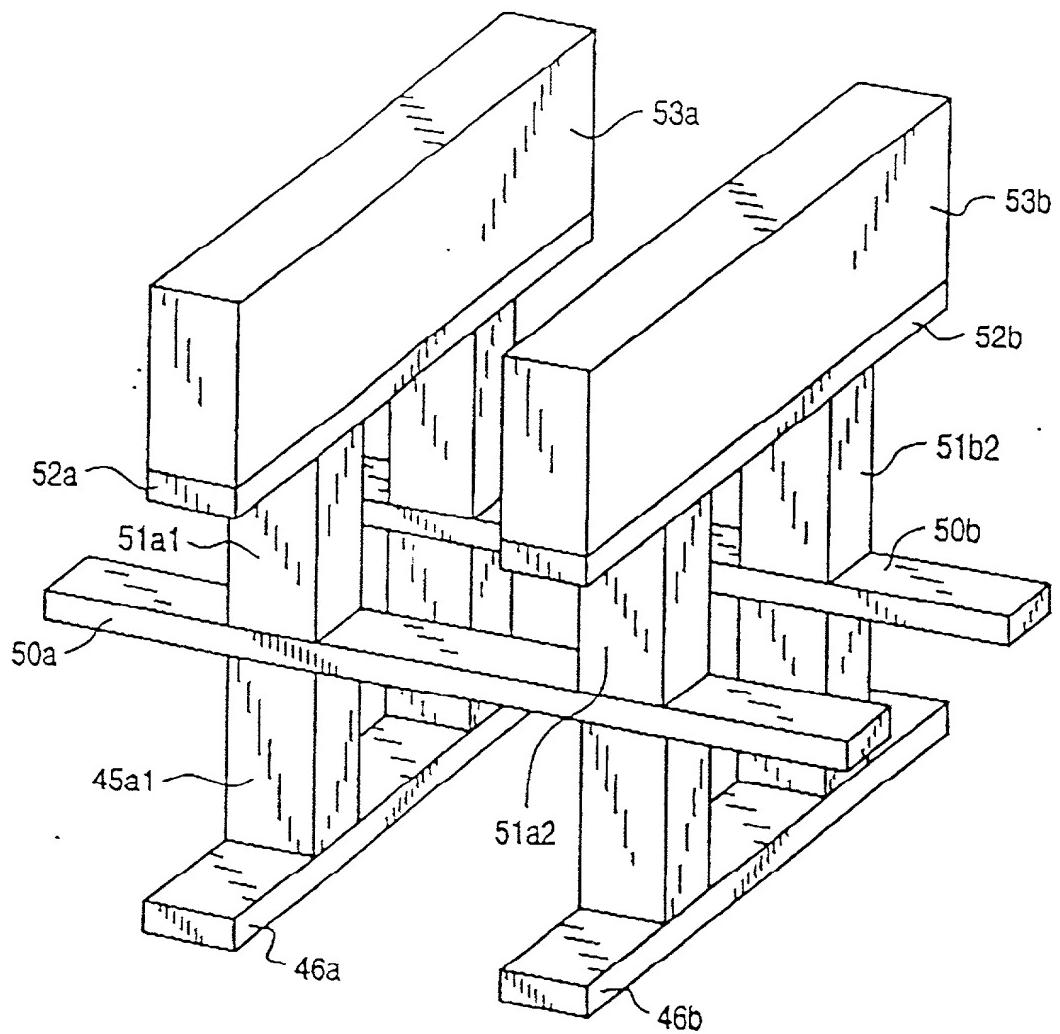


FIG. 6(g)

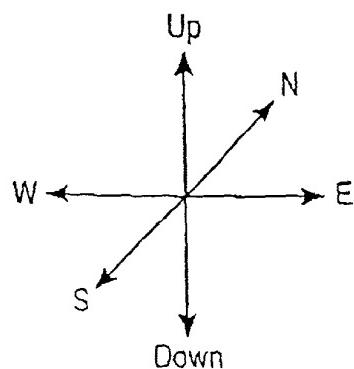
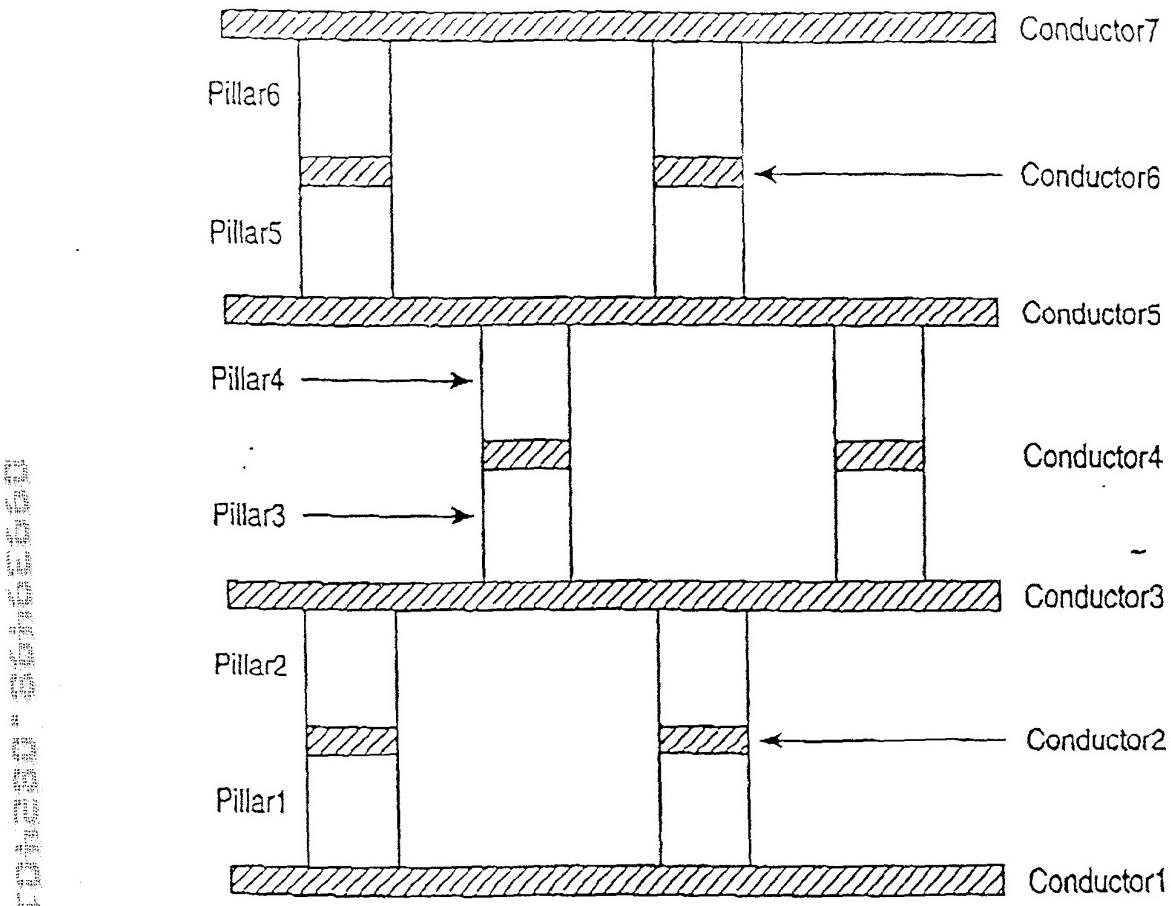


FIG. 7

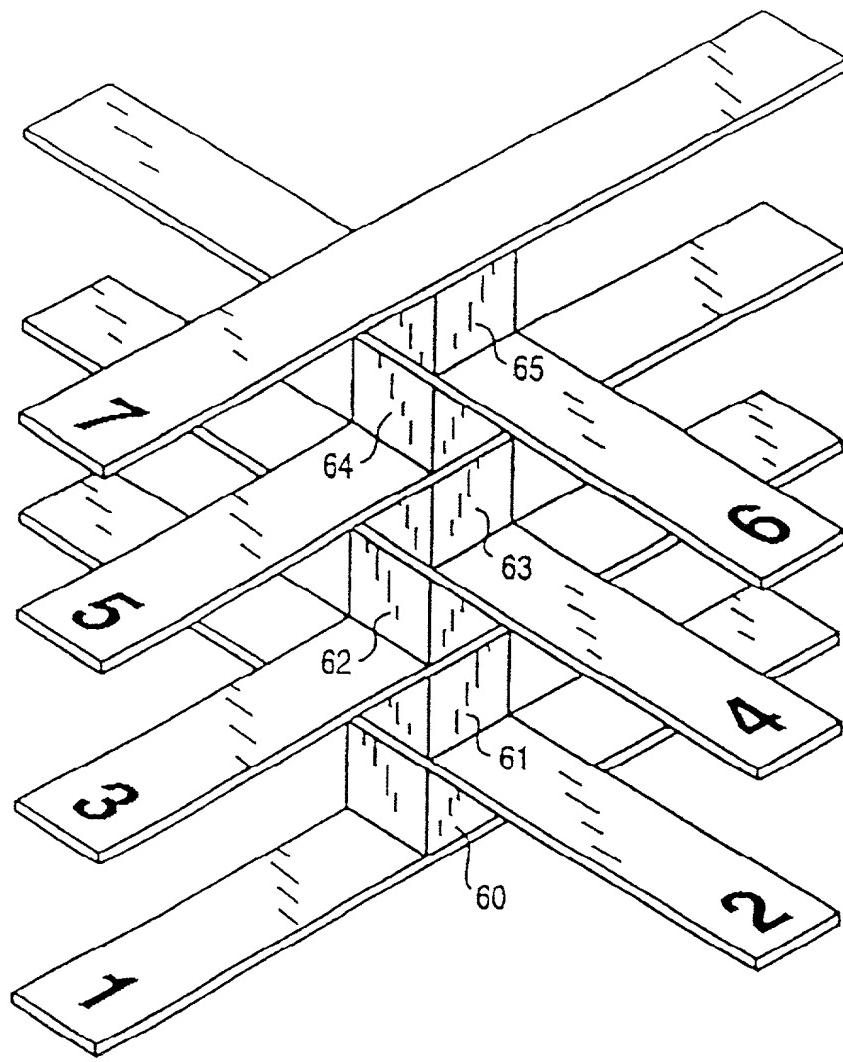


FIG. 8(a)

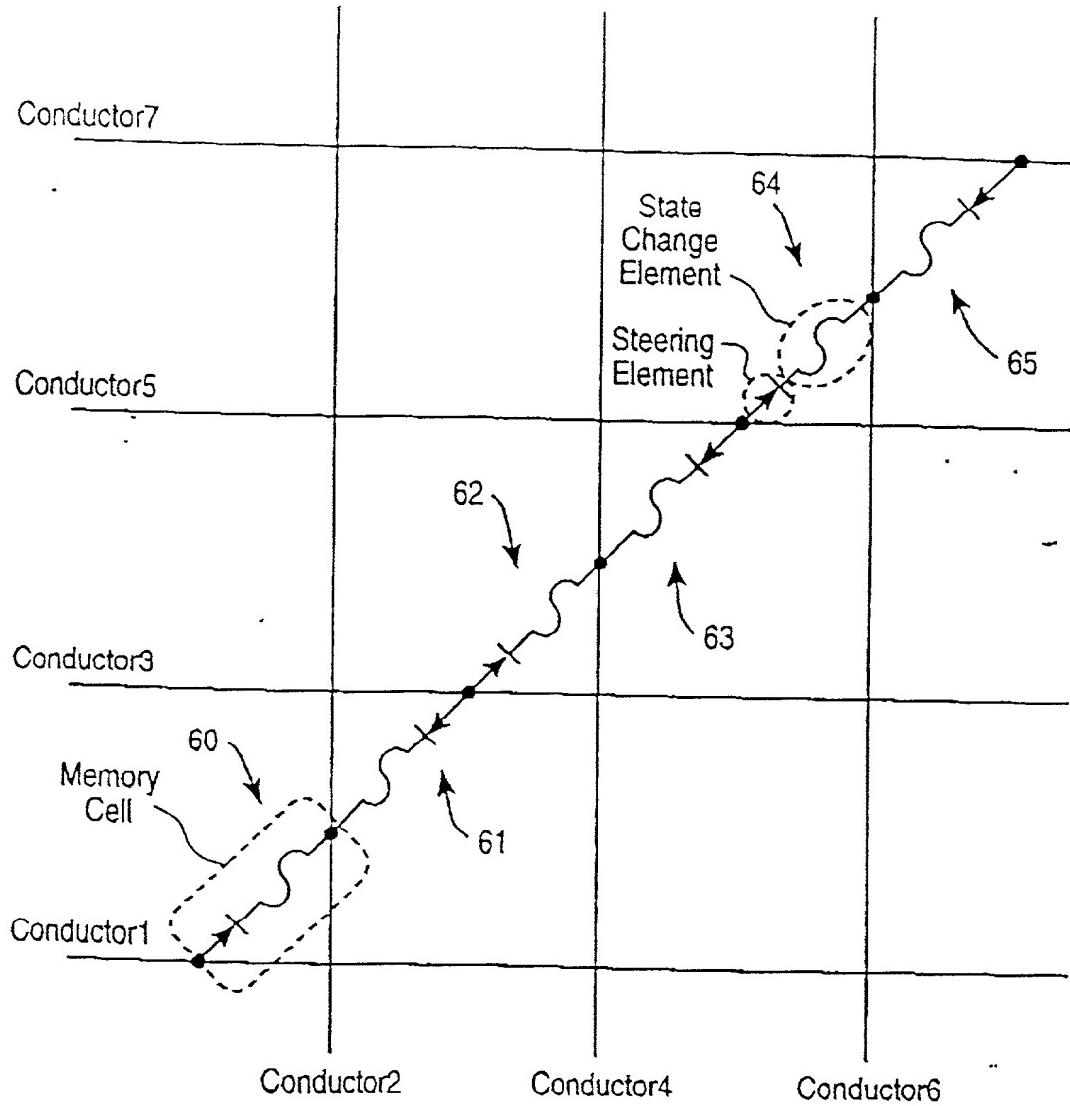


FIG. 8(b)

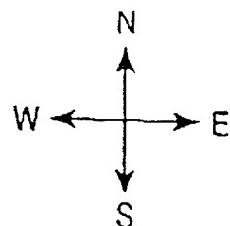
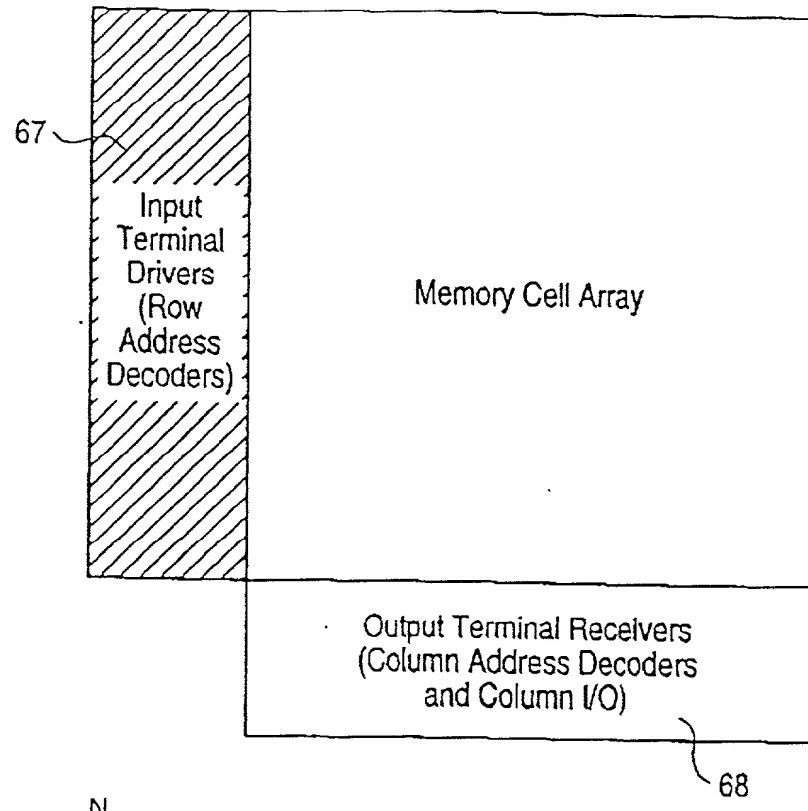


FIG. 9(a)

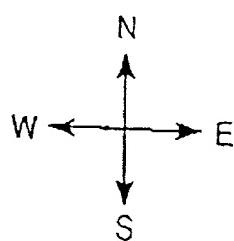
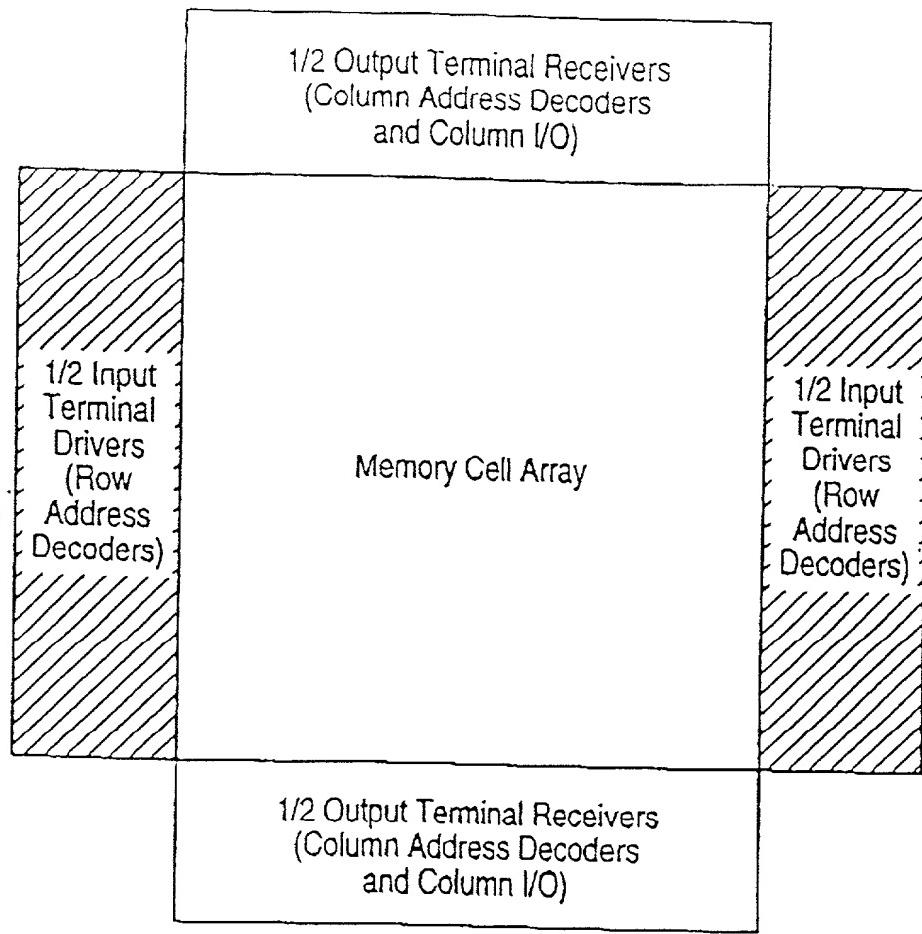


FIG. 9(b)

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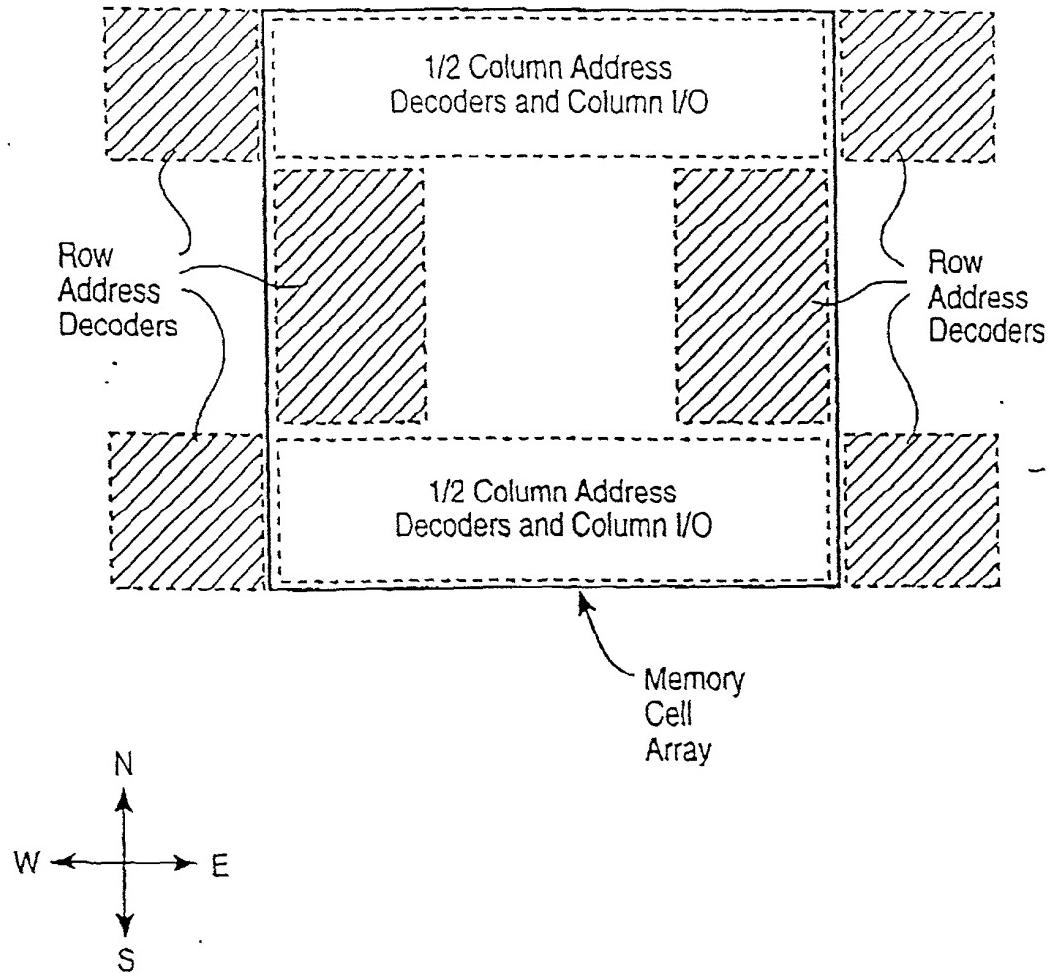


FIG. 9(c)

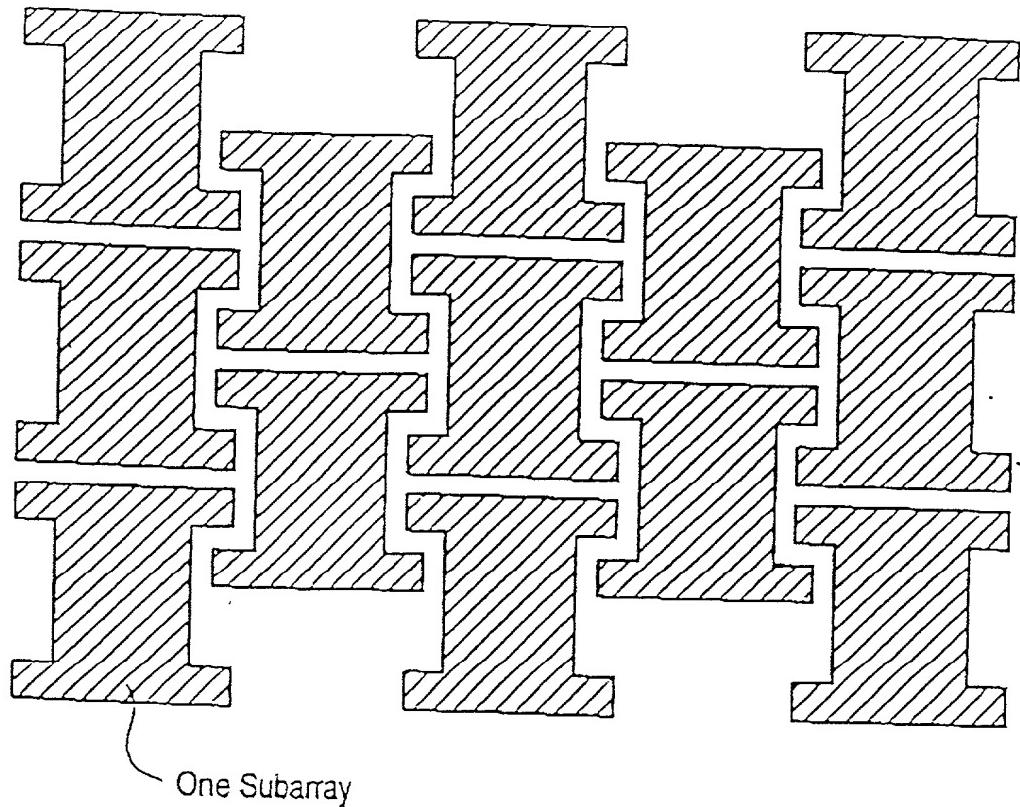


FIG. 9(d)

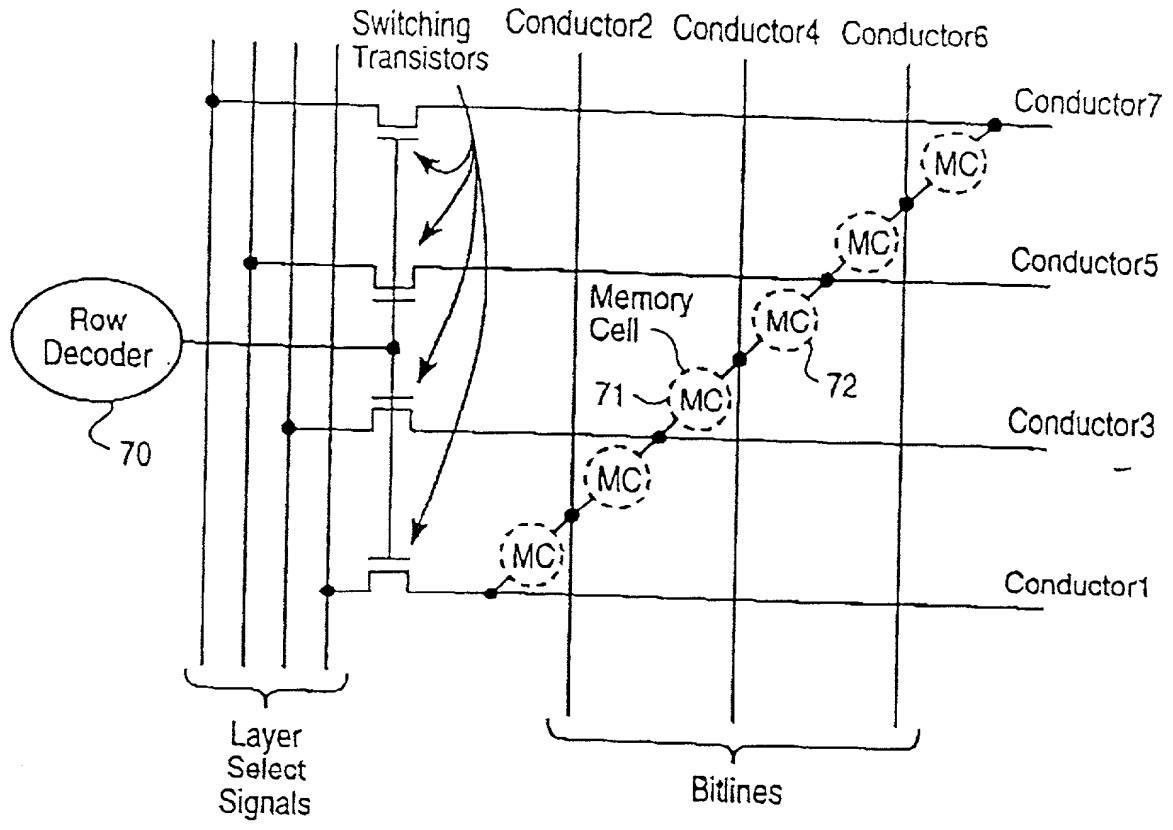


FIG. 10(a)

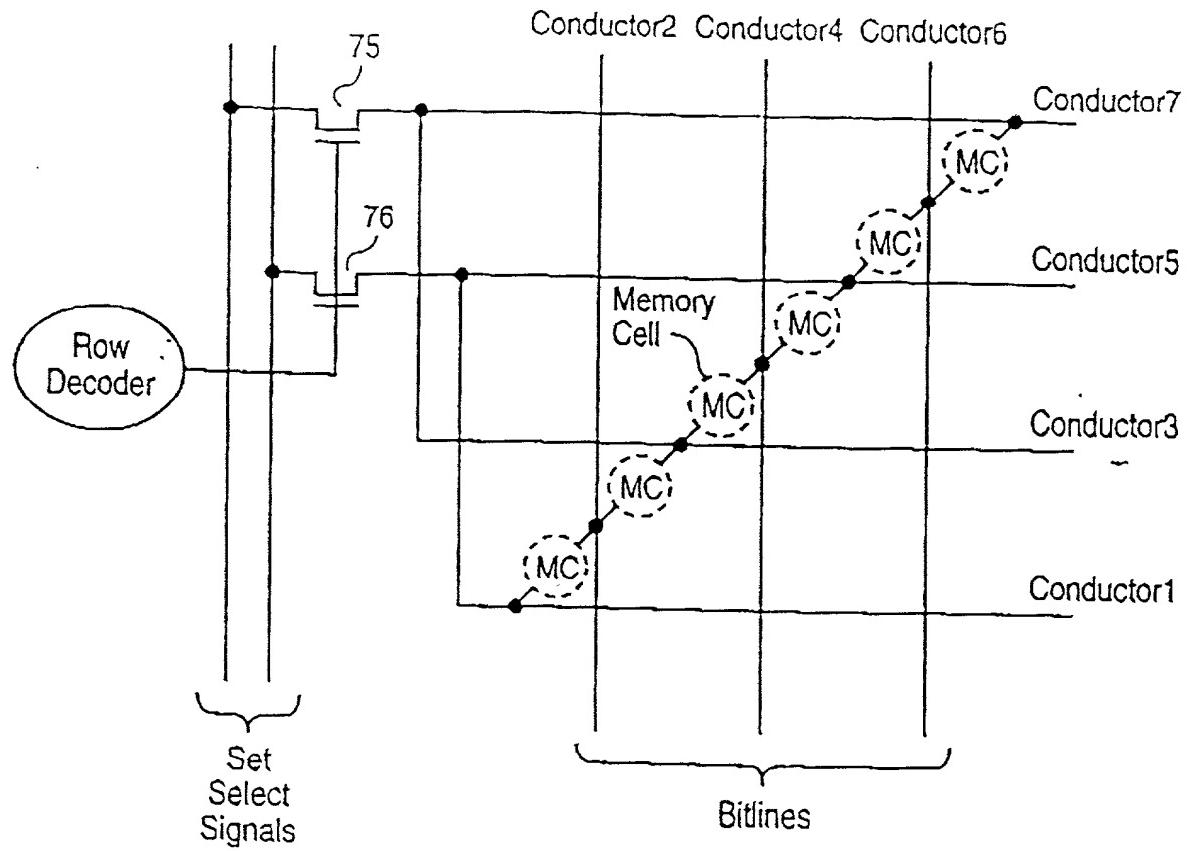


FIG. 10(b)

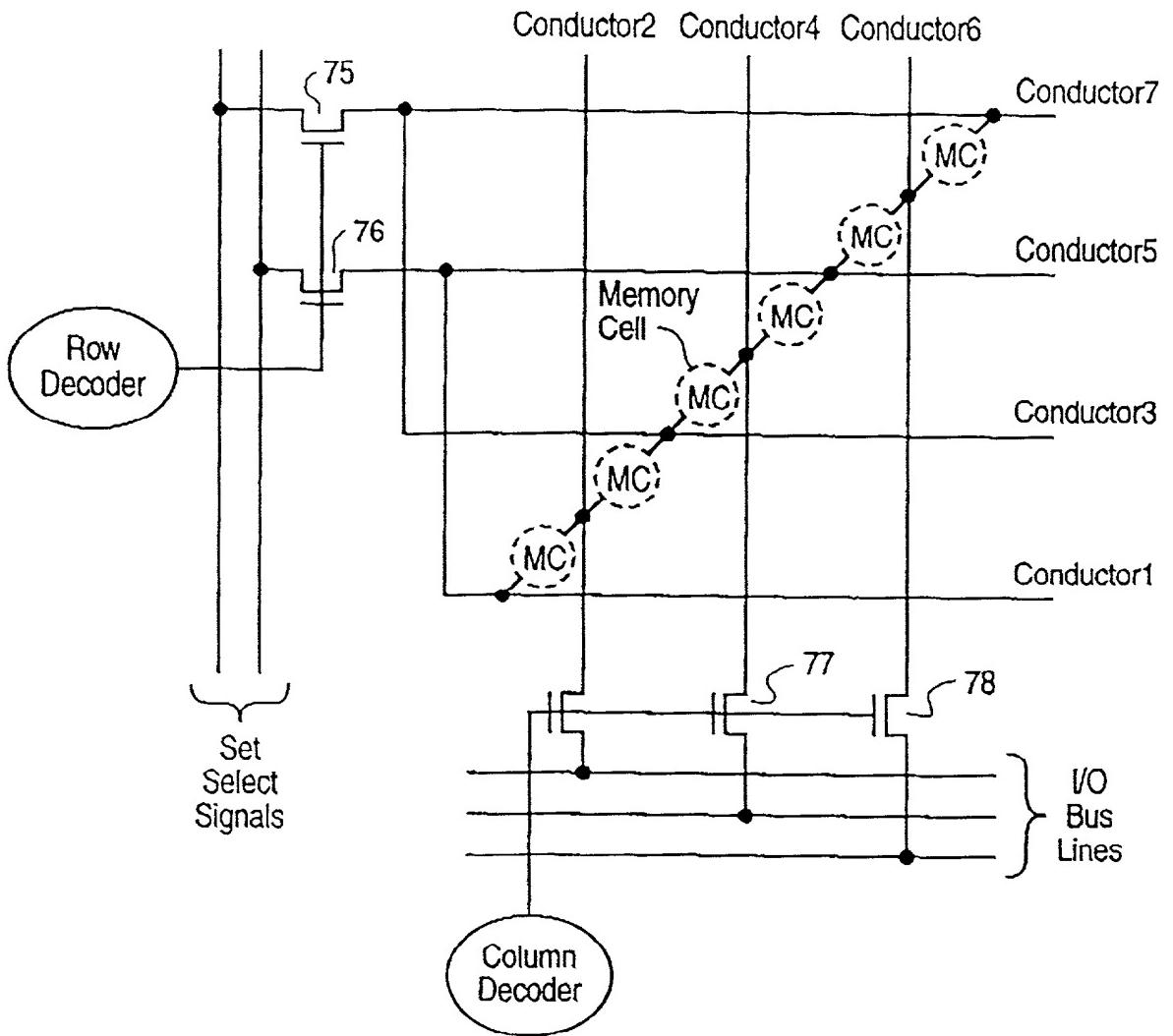


FIG. 11

Level 3

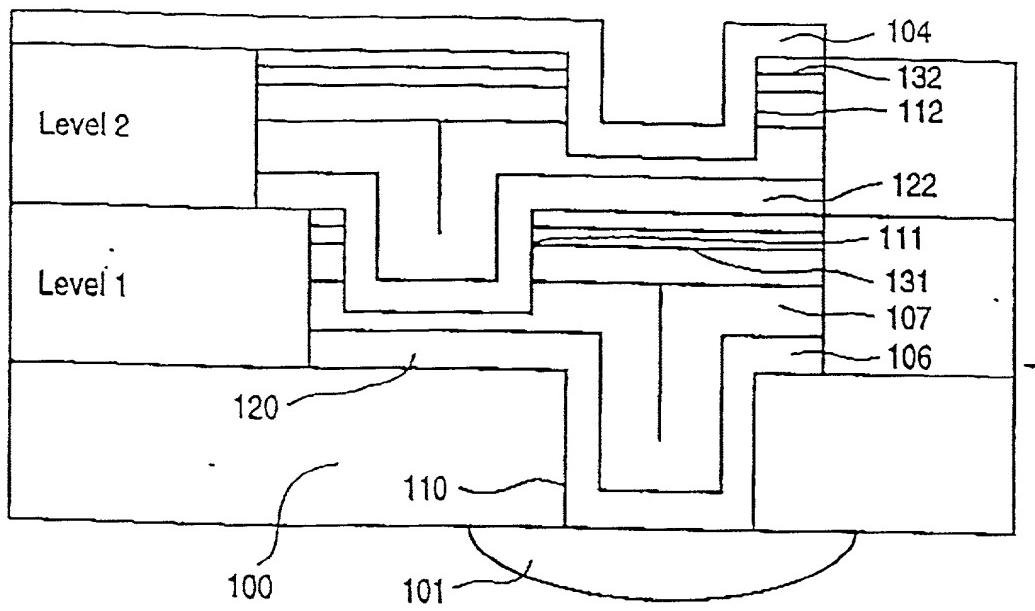


FIG. 12

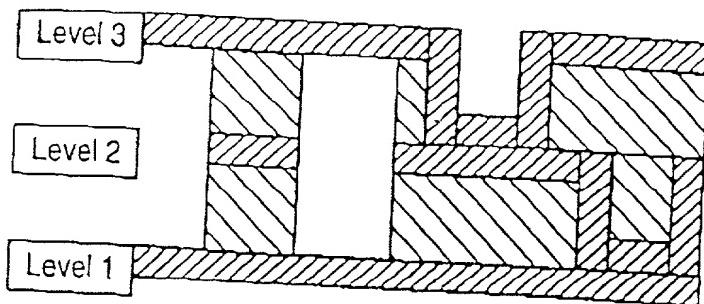


FIG. 13(a)

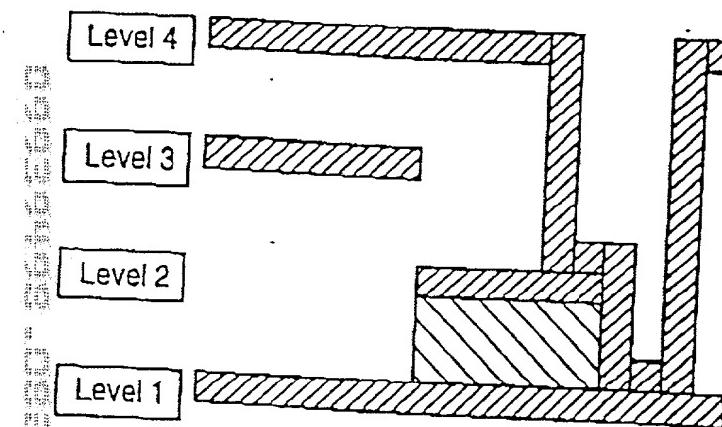


FIG. 13(b)

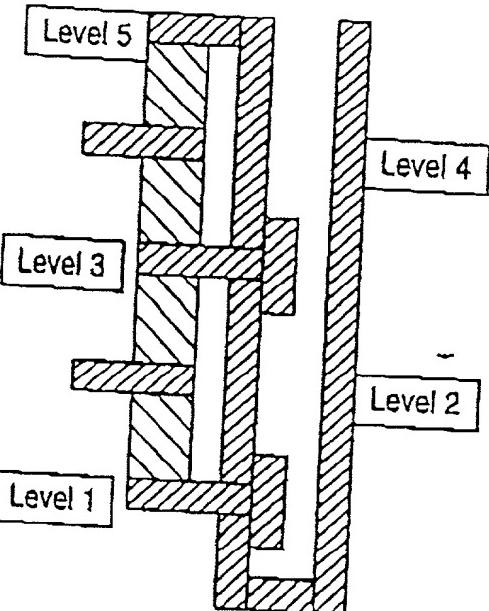


FIG. 13(c)

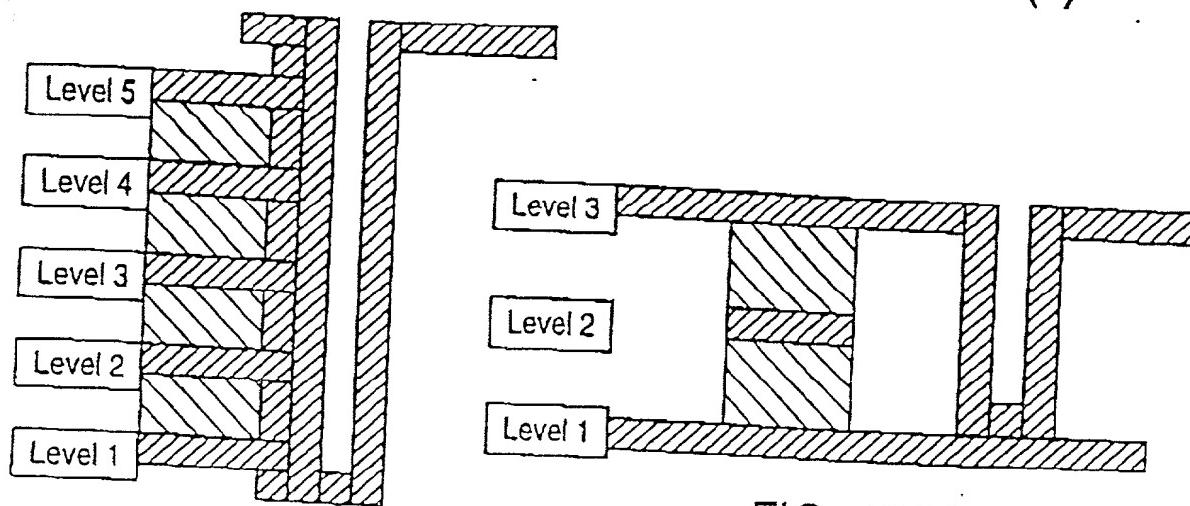


FIG. 13(d)

FIG. 13(e)